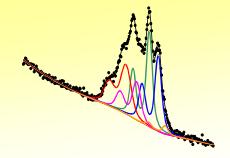




Batch Processing – from the Measured Spectrum to the High Quality Presentation Using the XPS Software UNIFIT 2009 only

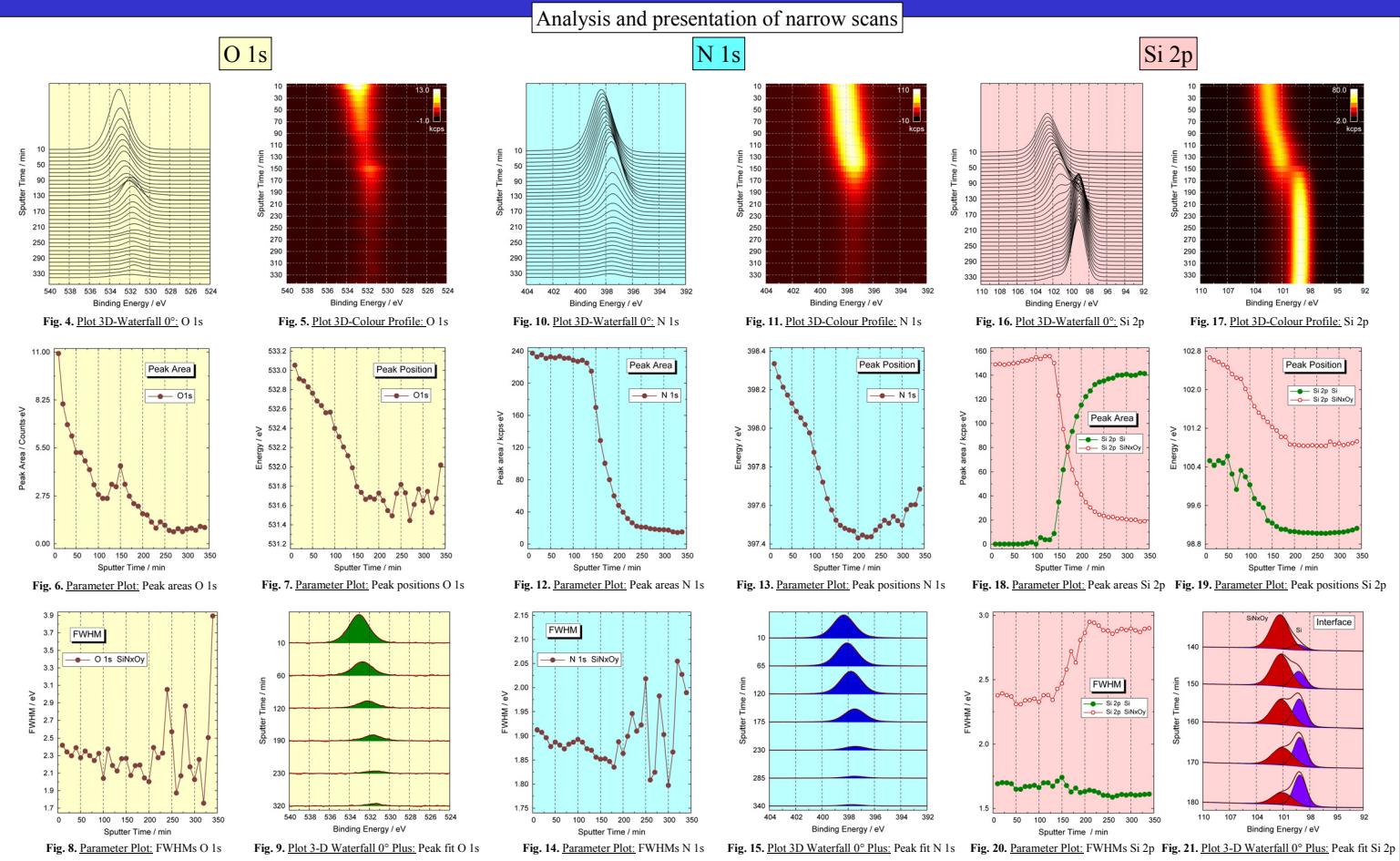
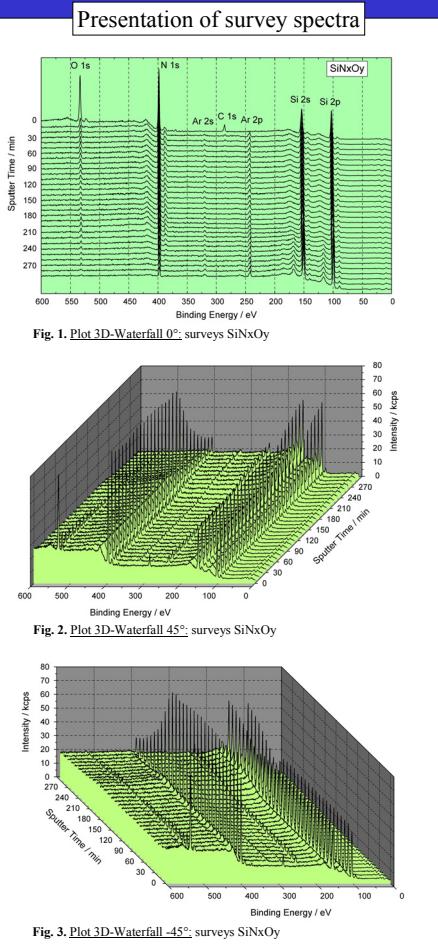
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Website: www.uni-leipzig.de/~unifit Contact: rhesse@rz.uni-leipzig.de

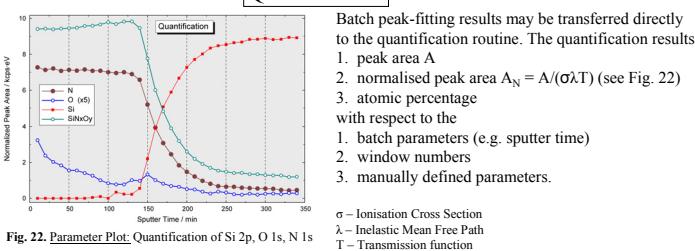


Case study: Sputter depth profile on Si_3N_4 films

Problem: O and N distributions with respect to depth



Quantification



Processing:

1. Simultaneous displaying and processing of up to 100 windows,
2. including all spectrum modifications, e.g. reduction, differentiation, smoothing, etc.,
3. normalisation to maximum, minimum, manually defined value or intensity at a certain energy,
4. peak fit using different
 - model functions (product, sum or convolution),
 - peak species (singlet peaks or doublet peaks),
 - fit parameters (absolute or relative),
5. integration of a fitable background consisting of
 - polynomial 3rd degree,
 - Shirley background,
 - Tougaard background (with variable loss functions).

Batch procedures

Presentation:

1. Plot 3D-Waterfall 0°: Plot of spectra (see Fig. 1) or sum curves of the peak fit (see Fig. 4, 10, 16) with a viewing angle of 0°,
2. Plot 3D-Waterfall 45°: Plot of spectra (see Fig. 2) or sum curves with 45° viewing,
3. Plot 3D-Waterfall -45°: Plot of spectra (see Fig. 3) or sum curves with -45° viewing,
4. Plot 3D-Colour Profile: Plot of the intensity of spectra or sum curves as brightness (see Fig. 5, 11, 17),
5. Plot 3D-Waterfall 0° Plus: Plot of fitted spectra (see Fig. 9, 15, 21),
6. Plot Fit Parameter: Plot of fit parameters, e.g. peak position (see Fig. 7, 13, 19), peak area (see Fig. 6, 12, 18), FWHM (see Fig. 8, 14, 20), peak height, etc.,
7. Parameter Plot of the quantification results, e.g. peak area, normalized peak area (see Fig. 22) or atomic percentage.